PATENT ABSTRACTS OF JAPAN

(11) Publication number: 01026505 A(43) Date of publication of application: 27.01.1989

(51) Int. Cl A61K 6/08

A61K 6/00, C08G 75/02

(21) Application number: 62181225 (71) Applicant: SHOWA DENKO KK

(22) Date of filing: 22.07.1987 (72) Inventor: TAKENOSHITA YOUICHIROU

YOSHIDA HARUO

(54) PHOTO-SETTING COMPOSITION FOR DENTAL MATERIAL

(57) Abstract:

PURPOSE: To provide the titled composition composed of a specific liquid thioether-type polymerizable monomer and a polymerizable polyfunctional vinyl monomer, having excellent polymerization curability at normal temperature and giving a cured product having excellent hardness and strength.

CONSTITUTION: The objective composition is produced by compounding (A) \geq 50wt.% of a liquid thioether-type monomer produced by the addition reaction of (A₁) a polyene compound of formula I [R¹ and R² are H or CH₃; R³ is 2W20C (OH-containing) aliphatic polyhydric alcohol residue or polyalkylene ether polyol residue; m is 1 or 2] with (A₂) a polythiol compound of formula II [R⁴ is 2W10C (OH-containing) polyvalent aliphatic hydrocarbon residue;

p is 1W4] and/or formula III [R 5 is 2W20C (OH-containing) aliphatic polyhydric alcohol residue; q is 1 or 2; r is 1W4] in the presence of a basic catalyst at a functional group equivalent ratio (A $_1$ /A $_2$) of 2W10 with (B) \leq 50wt.% of a polyfunctional vinyl monomer, e.g. the compound of formula such as bis(β -acryloyloxyethyl)phthalate.

COPYRIGHT: (C)1989,JPO&Japio